MgO Tunnel Barriers and Method of Formation

Abstract

5 MgO tunnel barriers are formed by depositing a thin layer of Mg on a suitable

underlayer, and then directing oxygen and additional Mg towards the Mg layer. The

oxygen reacts with the additional Mg and the Mg in the Mg layer to form a MgO tunnel

barrier that enjoys excellent tunneling characteristics. The MgO tunnel barriers so

formed may be used in magnetic tunnel junctions having tunneling magnetoresistance

(TMR) values of greater than 100%. The highest TMR values are observed for junctions

that have been annealed.

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